	Hits	Search Text	DBs
1	335	(((resist or photoresist) near12 pattern) same ((surfactant or non$4ionic$4surfactant or polyoxyethylene or (polyoxyalkylene near8 ether) or (sorbitan near9 fatty near9 acid) or (glycerol near9 fatty near9 ester) or (phenol near9 ethoxylate) or alkoxylate or amide or alcohol or (ethylene near4 diamine)) near16 (solution or solvent) near26 (aqueous or water)) same (apply$4 or coat$4 or form$4 or deposit$4))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
2	0	(((resist or photoresist) near12 pattern) same ((surfactant or non$4ionic$4surfactant or polyoxyethylene or (polyoxyalkylene near8 ether) or (sorbitan near9 fatty near9 acid) or (glycerol near9 fatty near9 ester) or (phenol near9 ethoxylate) or alkoxylate or amide or alcohol or (ethylene near4 diamine)) near16 (solution or solvent) near26 (aqueous or water)) same (apply$4 or coat$4 or form$4 or deposit$4) same (top or protective or upper) near16 (coat$4 or form$4 or deposit$4 or layer or film) near16 (thicken$4 or modify$5 or third) near16 (water or alkali) near12 (solub$5) near22 (poly$4vinyl$3alcohol or poly$4vinyl$3acetate or polyvinylpyrrolidone or poly$2acrylic$3acid or poly$2vinyl$4acetal))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
3	0	(((resist or photoresist) near12 pattern) same ((surfactant or non$4ionic$4surfactant or polyoxyethylene or (polyoxyalkylene near8 ether) or (sorbitan near9 fatty near9 acid) or (glycerol near9 fatty near9 ester) or (phenol near9 ethoxylate) or alkoxylate or amide or alcohol or (ethylene near4 diamine)) near16 (solution or solvent) near26 (aqueous or water)) same (apply$4 or coat$4 or form$4 or deposit$4) same ((coat$4 or form$4 or deposit$4 or layer or film) near16 (thicken$4 or modify$5 or protect$4) near16 (water or alkali) near22 (poly$4vinyl$3alcohol or poly$4vinyl$3acetate or polyvinylpyrrolidone or poly$2acrylic$3acid or poly$2vinyl$4acetal)))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
4	8	(((resist or photoresist) near12 pattern) same ((surfactant or non$4ionic$4surfactant or polyoxyethylene or (polyoxyalkylene near8 ether) or (sorbitan near9 fatty near9 acid) or (glycerol near9 fatty near9 ester) or (phenol near9 ethoxylate) or alkoxylate or amide or alcohol or (ethylene near4 diamine))) same (apply$4 or coat$4 or form$4 or deposit$4)) and ((thicken$4 or protect$4 or modif$5) same (polyvinylpyrrolid$4 or poly$4vinyl$3alcohol or poly$4vinyl$3acetate or polyvinylpyrrolidone or poly$2acrylic$3acid or poly$2vinyl$4acetal))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
5	2	(((resist or photoresist) near12 pattern) same ((surfactant or non$4ionic$4surfactant or polyoxyethylene or (polyoxyalkylene near8 ether) or (sorbitan near9 fatty near9 acid) or (glycerol near9 fatty near9 ester) or (phenol near9 ethoxylate) or alkoxylate or amide or alcohol or (ethylene near4 diamine)) near16 (solution or solvent) near26 (aqueous or water)) same (apply$4 or coat$4 or form$4 or deposit$4)) and ((resist near12 pattern) same (thicken$4 or protect$4 or modif$5) same (polyvinylpyrrolid$4 or poly$4vinyl$3alcohol or poly$4vinyl$3acetate or polyvinylpyrrolidone or poly$2acrylic$3acid or poly$2vinyl$4acetal))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
6	3	(("20010006752") or ("20010036594") or ("20020120058")).PN.	US-PGPUB; USPAT

	Hits	Search Text	DBs
7	5	(((resist or photoresist) near12 pattern) same ((surfactant or non$4ionic$4surfactant or polyoxyethylene or (polyoxyalkylene near8 ether) or (sorbitan near9 fatty near9 acid) or (glycerol near9 fatty near9 ester) or (phenol near9 ethoxylate) or alkoxylate or amide or alcohol or (ethylene near4 diamine)) near16 (solution or solvent) near26 (aqueous or water)) same (apply$4 or coat$4 or form$4 or deposit$4)) and ((thicken$4 or protect$4 or modif$5) same (polyvinylpyrrolid$4 or poly$4vinyl$3alcohol or poly$4vinyl$3acetate or polyvinylpyrrolidone or poly$2acrylic$3acid or poly$2vinyl$4acetal))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
8	13	(((resist or photoresist) near12 pattern) same ((surfactant or non$4ionic$4surfactant or polyoxyethylene or (polyoxyalkylene near8 ether) or (sorbitan near9 fatty near9 acid) or (glycerol near9 fatty near9 ester) or (phenol near9 ethoxylate) or alkoxylate or amide or alcohol or (ethylene near4 diamine))) same (apply$4 or coat$4 or form$4 or deposit$4)) and ((thicken$4 or protect$4 or modif$5 or (top near9 layer) or (form$4 near9 resist)) same (polyvinylpyrrolid$4 or poly$4vinyl$3alcohol or poly$4vinyl$3acetate or polyvinylpyrrolidone or poly$2acrylic$3acid or poly$2vinyl$4acetal))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
9	0	((resist or photoresist) near12 pattern) and (((surfactant or non$4ionic$4surfactant or polyoxyethylene or (polyoxyalkylene near8 ether) or (sorbitan near9 fatty near9 acid) or (glycerol near9 fatty near9 ester) or (phenol near9 ethoxylate) or alkoxylate or amide or alcohol or (ethylene near4 diamine)) near16 (solution or solvent) near26 (aqueous or water or alkali)) same (apply$4 or coat$4 or form$4 or deposit$4) same ((top or protective or upper) near16 (coat$4 or form$4 or deposit$4 or layer or film) near16 (thicken$4 or modify$5 or third) near16 (water or alkali) near12 (solub$5) near22 (poly$4vinyl$3alcohol or poly$4vinyl$3acetate or polyvinylpyrrolidone or poly$2acrylic$3acid or poly$2vinyl$4acetal)))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
10	2	((resist or photoresist) near12 pattern) and (((surfactant or non$4ionic$4surfactant or polyoxyethylene or (polyoxyalkylene near8 ether) or (sorbitan near9 fatty near9 acid) or (glycerol near9 fatty near9 ester) or (phenol near9 ethoxylate) or alkoxylate or amide or alcohol or (ethylene near4 diamine)) near16 (solution or solvent) near26 (aqueous or water or alkali)) same (apply$4 or coat$4 or form$4 or deposit$4) same ((top or protective or upper or thicken$4 or modif$5) near16 (coat$4 or form$4 or deposit$4 or layer or film) near16 (water or alkali) near19 (solub$6) near22 (poly$4vinyl$3alcohol or poly$4vinyl$3acetate or polyvinylpyrrolidone or poly$2acrylic$3acid or poly$2vinyl$4acetal)))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
11	3	((resist or photoresist) near12 pattern) and (((surfactant or non$4ionic$4surfactant or polyoxyethylene or (polyoxyalkylene near8 ether) or (sorbitan near9 fatty near9 acid) or (glycerol near9 fatty near9 ester) or (phenol near9 ethoxylate) or alkoxylate or amide or alcohol or (ethylene near4 diamine)) near16 (solution or solvent) near26 (aqueous or water or alkali)) same (apply$4 or coat$4 or form$4 or deposit$4)) and ((top or protective or upper or thicken$4 or modif$5) near16 (coat$4 or form$4 or deposit$4 or layer or film) near16 (water or alkali) near19 (solub$6) near22 (poly$4vinyl$3alcohol or poly$4vinyl$3acetate or polyvinylpyrrolidone or poly$2acrylic$3acid or poly$2vinyl$4acetal))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
12	21	((resist or photoresist) near12 pattern) and (((surfactant or non$4ionic$4surfactant or polyoxyethylene or (polyoxyalkylene near8 ether) or (sorbitan near9 fatty near9 acid) or (glycerol near9 fatty near9 ester) or (phenol near9 ethoxylate) or alkoxylate or amide or alcohol or (ethylene near4 diamine)) near16 (solution or solvent or aqueous or water or alkali)) same (apply$4 or coat$4 or form$4 or deposit$4)) and ((top or protective or upper or thicken$4 or modif$5 or swell$5) near16 (coat$4 or form$4 or deposit$4 or layer or film) near22 (poly$4vinyl$3alcohol or poly$4vinyl$3acetate or polyvinylpyrrolidone or poly$2acrylic$3acid or poly$2vinyl$4acetal))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
13	28	((resist or photoresist) near12 pattern) and ((surfactant or non$4ionic$4surfactant or polyoxyethylene or (polyoxyalkylene near8 ether) or (sorbitan near9 fatty near9 acid) or (glycerol near9 fatty near9 ester) or (phenol near9 ethoxylate) or alkoxylate or amide or alcohol or (ethylene near4 diamine)) same (apply$4 or coat$4 or form$4 or deposit$4)) and ((top or protective or upper or thicken$4 or modif$5 or swell$5) near16 (coat$4 or form$4 or deposit$4 or layer or film) near22 (poly$4vinyl$3alcohol or poly$4vinyl$3acetate or polyvinylpyrrolidone or poly$2acrylic$3acid or poly$2vinyl$4acetal))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
14	8	((surfactant or non$4ionic$4surfactant or polyoxyethylene or (polyoxyalkylene near8 ether) or (sorbitan near9 fatty near9 acid) or (glycerol near9 fatty near9 ester) or (phenol near9 ethoxylate) or alkoxylate or amide or alcohol or (ethylene near4 diamine)) same (apply$4 or coat$4 or form$4 or deposit$4 or treat$4) same ((resist or photoresist) near9 (pattern or structure))) and ((top or protective or upper or thicken$4 or modif$5 or swell$5) same (coat$4 or form$4 or deposit$4 or layer or film) same (poly$4vinyl$3alcohol or poly$4vinyl$3acetate or polyvinylpyrrolidone or poly$2acrylic$3acid or poly$2vinyl$4acetal))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
15	8	(((surface near9 active near6 agent) or surfactant or non$4ionic$4surfactant or polyoxyethylene or (polyoxyalkylene near8 ether) or (sorbitan near9 fatty near9 acid) or (glycerol near9 fatty near9 ester) or ((phenol or alcohol) near9 ethoxylate) or alkoxylate or amide or alcohol or (ethylene near4 diamine)) same (apply$4 or coat$4 or form$4 or deposit$4 or treat$4) same ((resist or photoresist) near9 (pattern or structure))) and ((top or protective or upper or thicken$4 or modif$5 or swell$5) same (coat$4 or form$4 or deposit$4 or layer or film) same (poly$4vinyl$3alcohol or poly$4vinyl$3acetate or poly$4vinyl$5pyrrolidone or poly$3acrylic$4acid or poly$2vinyl$4acetal))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
16	71	((non$4ionic$4surfactant or polyoxyethylene or (polyoxyalkylene near8 ether) or (sorbitan near9 fatty near9 acid) or (glycerol near9 fatty near9 ester) or (phenol near9 ethoxylate) or alkoxylate or amide or alcohol or (ethylene near4 diamine)) near12 (apply$4 or coat$4 or form$4 or deposit$4 or treat$4) near8 (resist or photoresist) near9 (pattern or structure)) and ((third or second or thicken$4 or swell$4) near9 resist near9 (film or coat$4 or layer))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB